

Title (en)

METHODS FOR FABRICATING ISOLATED MICRO- AND NANO- STRUCTURES USING SOFT OR IMPRINT LITHOGRAPHY

Title (de)

VERFAHREN ZUR HERSTELLUNG ISOLIERTER MIKRO- UND NANOSTRUKTUREN UNTER VERWENDUNG VON SOFT- ODER DRUCK- LITHOGRAPHIE

Title (fr)

PROCEDE DE FABRICATION DE MICROSTRUCTURES ET DE NANOSTRUCTURES AU MOYEN DE LA LITHOGRAPHIE MOLLE OU D'IMPRESSION

Publication

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Application

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Abstract (en)

[origin: WO2005101466A2] The presently disclosed subject matter describes the use of fluorinated elastomer-based materials, in particular perfluoropolyether (PFPE)-based materials, in high-resolution soft or imprint lithographic applications, such as micro- and nanoscale replica molding, and the first nano-contact molding of organic materials to generate high fidelity features using an elastomeric mold. Accordingly, the presently disclosed subject matter describes a method for producing free-standing, isolated nanostructures of any shape using soft or imprint lithography techniques.

IPC 8 full level

H01L 21/302 (2006.01); **A61K 9/00** (2006.01); **A61K 9/51** (2006.01); **B81C 99/00** (2010.01); **G03F 7/00** (2006.01); **H01L 21/02** (2006.01); **H01L 51/00** (2006.01); **H01L 51/40** (2006.01)

CPC (source: EP KR US)

A61K 9/0097 (2013.01 - EP KR US); **A61K 9/14** (2013.01 - KR US); **A61K 9/5138** (2013.01 - EP KR US); **A61K 9/5153** (2013.01 - EP KR US); **A61K 9/5192** (2013.01 - EP KR US); **A61K 47/34** (2013.01 - US); **B81C 99/0085** (2013.01 - EP KR US); **B82Y 10/00** (2013.01 - EP US); **B82Y 40/00** (2013.01 - EP US); **G03F 7/0002** (2013.01 - EP KR US); **H01L 21/0274** (2013.01 - KR); **H10K 71/13** (2023.02 - KR); **H10K 71/60** (2023.02 - KR); **B82Y 40/00** (2013.01 - KR); **H10K 71/13** (2023.02 - EP US); **H10K 71/60** (2023.02 - EP US); **Y02E 10/549** (2013.01 - EP); **Y02P 70/50** (2015.11 - EP); **Y10T 428/24273** (2015.01 - EP US); **Y10T 428/24479** (2015.01 - EP US); **Y10T 428/3154** (2015.04 - EP US)

Citation (examination)

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